

# Hiroshi Uchida

## List of Publications by Year in descending order

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times ranked

2141  
citing authors

#	ARTICLE	IF	CITATIONS
1	Crystal structure and ferroelectric properties of rare-earth substituted BiFeO <sub>3</sub> thin films. Journal of Applied Physics, 2006, 100, 014106.	2.5	228
2	Impact of mechanical stress on ferroelectricity in (Hf <sub>0.5</sub> Zr <sub>0.5</sub> )O <sub>2</sub> thin films. Applied Physics Letters, 2016, 108, .	3.3	187
3	Approach for enhanced polarization of polycrystalline bismuth titanate films by Nd <sup>3+</sup> /V <sup>5+</sup> cosubstitution. Applied Physics Letters, 2002, 81, 2229-2231.	3.3	157
4	Ion Modification for Improvement of Insulating and Ferroelectric Properties of BiFeO <sub>3</sub> Thin Films Fabricated by Chemical Solution Deposition. Japanese Journal of Applied Physics, 2005, 44, L561-L563.	1.5	89
5	Growth of (111)-oriented epitaxial and textured ferroelectric Y-doped HfO <sub>2</sub> films for downscaled devices. Applied Physics Letters, 2016, 109, .	3.3	62
6	Fabrication of M <sup>3+</sup> -Substituted and M <sup>3+</sup> /V <sup>5+</sup> -Cosubstituted Bismuth Titanate Thin Films [M=lanthanoid] by Chemical Solution Deposition Technique. Japanese Journal of Applied Physics, 2002, 41, 6820-6824.	1.5	61
7	Analysis for crystal structure of Bi(Fe,Sc)O <sub>3</sub> thin films and their electrical properties. Applied Physics Letters, 2007, 91, .	3.3	60
8	Orientation control and domain structure analysis of {100}-oriented epitaxial ferroelectric orthorhombic HfO <sub>2</sub> -based thin films. Journal of Applied Physics, 2016, 119, .	2.5	57
9	Dependence of Ferroelectric Properties on Thickness of BiFeO <sub>3</sub> Thin Films Fabricated by Chemical Solution Deposition. Japanese Journal of Applied Physics, 2005, 44, 8525-8527.	1.5	49
10	Thickness-dependent crystal structure and electric properties of epitaxial ferroelectric Y <sub>2</sub> O <sub>3</sub> -HfO <sub>2</sub> films. Applied Physics Letters, 2018, 113, .	3.3	48
11	A Novel Hydroxyapatite Fiber Mesh as a Carrier for Recombinant Human Bone Morphogenetic Protein-2 Enhances Bone Union in Rat Posterolateral Fusion Model. Spine, 2006, 31, 1194-1200.	2.0	45
12	Effect of the film thickness on the crystal structure and ferroelectric properties of (Hf <sub>0.5</sub> Zr <sub>0.5</sub> )O <sub>2</sub> thin films deposited on various substrates. Materials Science in Semiconductor Processing, 2017, 70, 239-245.	4.0	41
13	Synthesis of Magnesium Silicon Nitride by the Nitridation of Powders in the Magnesium-Silicon System. Journal of the Ceramic Society of Japan, 1997, 105, 934-939.	1.3	39
14	Electrophoretic Deposition of Au Nanocrystals inside Perpendicular Mesochannels of TiO <sub>2</sub> . Chemistry of Materials, 2008, 20, 6029-6040.	6.7	35
15	Atom probe microscopy of three-dimensional distribution of silicon isotopes in Si <sup>28</sup> ~Si <sup>30</sup> isotope superlattices with sub-nanometer spatial resolution. Journal of Applied Physics, 2009, 106, .	2.5	32
16	Highly-ordered mesoporous titania thin films prepared via surfactant assembly on conductive indium-tin-oxide/glass substrate and its optical properties. Thin Solid Films, 2010, 518, 3169-3176.	1.8	31
17	Evaluation of oxygen vacancies in ZnO single crystals and powders by micro-Raman spectroscopy. Journal of the Ceramic Society of Japan, 2017, 125, 445-448.	1.1	31
18	Formation of (111) orientation-controlled ferroelectric orthorhombic HfO <sub>2</sub> thin films from solid phase via annealing. Applied Physics Letters, 2016, 109, .	3.3	29

#	ARTICLE	IF	CITATIONS
19	Room-temperature deposition of ferroelectric HfO <sub>2</sub> -based films by the sputtering method. Applied Physics Letters, 2020, 116, .	3.3	28
20	The effects of neodymium content and site occupancy on spontaneous polarization of epitaxial (Bi <sub>4-<i>x</i></sub> Nd <sub><i>x</i></sub> )Ti <sub>3</sub> O <sub>12</sub> films. Journal of Applied Physics, 2005, 98, 024110.	2.5	26
21	Growth of Epitaxial 100-Oriented KNbO <sub>3</sub> –NaNbO <sub>3</sub> Solid Solution Films on (100)-SrRuO <sub>3</sub> ∥(100)SrTiO <sub>3</sub> by Hydrothermal Method and Their Characterization. Japanese Journal of Applied Physics, 2011, 50, 09ND11.	1.5	26
22	Electrical Properties of (110)-Oriented Nondoped Mg <sub>2</sub> Si Films with p-Type Conduction Prepared by RF Magnetron Sputtering Method. Journal of Electronic Materials, 2014, 43, 2269-2273.	2.2	25
23	Influence of lattice distortion and oxygen vacancies on the UV-driven/microwave-assisted TiO <sub>2</sub> photocatalysis. Journal of Photochemistry and Photobiology A: Chemistry, 2013, 265, 20-28.	3.9	24
24	Crystal structure and dielectric/ferroelectric properties of CSD-derived HfO <sub>2</sub> -ZrO <sub>2</sub> solid solution films. Ceramics International, 2017, 43, S501-S505.	4.8	24
25	Low-Temperature Deposition of Polycrystalline Titanium Oxide Thin Film on Si Substrate Using Supercritical Carbon Dioxide Fluid. Japanese Journal of Applied Physics, 2005, 44, 1901-1906.	1.5	23
26	Fabrication of ferroelectric Fe doped HfO <sub>2</sub> epitaxial thin films by ion-beam sputtering method and their characterization. Japanese Journal of Applied Physics, 2018, 57, 11UF02.	1.5	23
27	Spontaneous Polarization of Neodymium-Substituted Bi <sub>4</sub> Ti <sub>3</sub> O <sub>12</sub> Estimated from Epitaxially Grown Thin Films with in-Plane c-Axis Orientations. Japanese Journal of Applied Physics, 2004, 43, L309-L311.	1.5	22
28	Crystal Structure Analysis of Hydrothermally Synthesized Epitaxial (K <sub><i>x</i></sub> Na <sub>1-<i>x</i></sub> )NbO <sub>3</sub> Films. Japanese Journal of Applied Physics, 2013, 52, 09KA11.	1.5	22
29	Crystallization behavior and ferroelectric property of HfO <sub>2</sub> –ZrO <sub>2</sub> films fabricated by chemical solution deposition. Japanese Journal of Applied Physics, 2018, 57, 11UF06.	1.5	22
30	Probing intrinsic polarization properties in bismuth-layered ferroelectric films. Applied Physics Letters, 2007, 90, 112914.	3.3	21
31	Preparation of Barium Titanate and Strontium Titanate Nanocube Particles and their Accumulation Using Smart Glue. Key Engineering Materials, 2009, 421-422, 514-517.	0.4	21
32	Composition dependency of crystal structure, electrical and piezoelectric properties for hydrothermally-synthesized 3 μm-thickness (K <sub><i>x</i></sub> Na <sub>1-<i>x</i></sub> )NbO <sub>3</sub> films. Journal of the Ceramic Society of Japan, 2013, 121, 627-631.	1.1	21
33	Low temperature deposition of titanium oxide containing thin films in trench features from titanium diisopropoxide bis(dipivaloylmethanate) in supercritical CO <sub>2</sub> . Journal of Supercritical Fluids, 2009, 50, 313-319.	3.2	19
34	Ferroelectric and piezoelectric properties of (K,Na)NbO <sub>3</sub> thick films prepared on metal substrates by hydrothermal method. Journal of the Korean Physical Society, 2013, 62, 1055-1059.	0.7	19
35	The effect of rare-earth oxide addition on the hot-pressing of magnesium silicon nitride. Journal of the European Ceramic Society, 2002, 22, 777-783.	5.7	18
36	Solubility of titanium diisopropoxide bis(dipivaloylmethanate) complex in supercritical carbon dioxide and its effect on supercritical fluid deposition process. Journal of Supercritical Fluids, 2012, 66, 59-65.	3.2	18

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37	Vibration-energy-harvesting properties of hydrothermally synthesized (K,Na)NbO <sub>3</sub> films deposited on flexible metal foil substrates. Japanese Journal of Applied Physics, 2015, 54, 10ND06.	1.5	18
38	Effects of starting materials on the deposition behavior of hydrothermally synthesized {111}-oriented epitaxial (K,Na)NbO <sub>3</sub> thick films and their ferroelectric and piezoelectric properties. Journal of Crystal Growth, 2019, 511, 1-7.	1.5	18
39	Preparation of magnesium silicon nitride powder by the carbothermal reduction technique. Advanced Powder Technology, 1999, 10, 133-143.	4.1	17
40	Charge-Compensative Ion Substitution of La <sup>3+</sup> -Substituted Bismuth Titanate Thin Films for Enhancement of Remanent Polarization. Japanese Journal of Applied Physics, 2004, 43, 2636-2639.	1.5	17
41	MOCVD Growth of Bi <sub>1.5</sub> Zn <sub>1.0</sub> Nb <sub>1.5</sub> O <sub>7</sub> (BZN) Epitaxial Thin Films and Their Electrical Properties. Japanese Journal of Applied Physics, 2005, 44, 6957-6959.	1.5	17
42	<I>IN VITRO</I> BIOLOGICAL EVALUATIONS OF THREE-DIMENSIONAL SCAFFOLD DEVELOPED FROM SINGLE-CRYSTAL APATITE FIBRES FOR TISSUE ENGINEERING OF BONE. Phosphorus Research Bulletin, 2004, 17, 262-268.	0.6	16
43	Visualized Kinetic Aspects of Decomposition of a Wood Block in Sub- and Supercritical Water. Industrial & Engineering Chemistry Research, 2005, 44, 2975-2981.	3.7	16
44	Raman spectroscopic study of aqueous alkali sulfate solutions at high temperature and pressure to yield precipitation. Journal of Supercritical Fluids, 2009, 49, 303-309.	3.2	16
45	Crystal Structure and Dielectric Property of Bismuth Layer-Structured Dielectric Films with c-Axis Preferential Crystal Orientation. Japanese Journal of Applied Physics, 2010, 49, 09MA02.	1.5	16
46	Electrical Properties of (Ca,Sr)Bi <sub>4</sub> Ti <sub>4</sub> O <sub>15</sub> Thin Films Fabricated Using a Chemical Solution Deposition Method. Japanese Journal of Applied Physics, 2003, 42, 5990-5993.	1.5	15
47	Enhancement of spontaneous polarization in lead zirconate titanate thin films by Dy <sup>3+</sup> substitution. Applied Physics Letters, 2005, 87, 182906.	3.3	15
48	Growth of (111)-oriented BaTiO <sub>3</sub> â€“Bi(Mg <sub>0.5</sub> Ti <sub>0.5</sub> )O <sub>3</sub> epitaxial films and their crystal structure and electrical property characterizations. Journal of Applied Physics, 2012, 111, .	2.5	15
49	Epitaxial ferroelectric Y-doped HfO <sub>2</sub> film grown by the RF magnetron sputtering. Japanese Journal of Applied Physics, 2018, 57, 11UF15.	1.5	15
50	Formation of BiFeO <sub>3</sub> â€“BiScO <sub>3</sub> Thin Films and Their Electrical Properties. Japanese Journal of Applied Physics, 2006, 45, 7321-7324.	1.5	14
51	Ferroelectric and piezoelectric properties of KNbO <sub>3</sub> films deposited on flexible organic substrate by hydrothermal method. Japanese Journal of Applied Physics, 2014, 53, 09PA10.	1.5	14
52	Enhancement of Polarization Property of PZT Film by Ion-Substitution Using Rare-Earth Elements. Japanese Journal of Applied Physics, 2005, 44, 6905-6909.	1.5	13
53	Mechanism of Contact Resistance Reduction in Nickel Silicide Films by Pt Incorporation. IEEE Transactions on Electron Devices, 2011, 58, 3778-3786.	3.0	13
54	Crystal Orientation Control of Bismuth Layer-Structured Dielectric Films Using Interface Layers of Perovskite-Type Oxides. Japanese Journal of Applied Physics, 2011, 50, 09NA04.	1.5	13

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55	Evaluation of oxygen vacancy in ZnO using Raman spectroscopy. , 2015, , .		13
56	Effect of Film Thickness and Crystal Orientation on the Constituent Phase in Epitaxial BiFeO <sub>3</sub> â€“BiCoO <sub>3</sub> Films Grown on SrTiO <sub>3</sub> Substrates. Japanese Journal of Applied Physics, 2010, 49, 09MB04.	1.5	12
57	Fabrication of Ion-Cosubstituted Bismuth Titanate Thin Films by Chemical Solution Deposition Method. Integrated Ferroelectrics, 2003, 52, 41-54.	0.7	11
58	Low strain sensitivity of the dielectric property of pyrochlore Biâ€“Znâ€“Nbâ€“O films. Applied Physics Letters, 2008, 92, 182901.	3.3	11
59	Three-Dimensional Dopant Characterization of Actual Metalâ€“Oxideâ€“Semiconductor Devices of 65 nm Node by Atom Probe Tomography. Applied Physics Express, 2013, 6, 046502.	2.4	11
60	Growth of epitaxial (K, Na)NbO <sub>3</sub> films with various orientations by hydrothermal method and their properties. Japanese Journal of Applied Physics, 2019, 58, SLLB14.	1.5	11
61	Fabrication and Evaluation of One-Axis Oriented Lead Zirconate Titanate Films Using Metalâ€“Oxide Nanosheet Interface Layer. Japanese Journal of Applied Physics, 2013, 52, 09KA04.	1.5	11
62	Polarization comparison of Pb(Zr,Ti)O <sub>3</sub> and Bi <sub>4</sub> Ti <sub>3</sub> O <sub>12</sub> -based ferroelectrics. Materials Science and Engineering B: Solid-State Materials for Advanced Technology, 2005, 118, 23-27.	3.5	10
63	Raman OH stretching frequency shifts in supercritical water and in O <sub>2</sub> - and acetone-aqueous solutions near the water critical point. Chemical Physics Letters, 2009, 477, 85-89.	2.6	10
64	Composition dependence of crystal structure and electrical properties for epitaxial films of Bi(Zn <sub>1/2</sub> Ti <sub>1/2</sub> )O <sub>3</sub> -BiFeO <sub>3</sub> solid solution system. Journal of the Ceramic Society of Japan, 2010, 118, 659-663.	1.1	10
65	Characterization of (111)-oriented epitaxial (K <sub>0.5</sub> Na <sub>0.5</sub> )NbO <sub>3</sub> thick films deposited by hydrothermal method. Japanese Journal of Applied Physics, 2017, 56, 10PF04.	1.5	10
66	Preparation of {001}<sub>c</sub>-oriented epitaxial (K, Na)NbO <sub>3</sub> thick films by repeated hydrothermal deposition technique. Journal of the Ceramic Society of Japan, 2018, 126, 281-285.	1.1	10
67	Growth of Epitaxial 100-Oriented KNbO <sub>3</sub> â€“NaNbO <sub>3</sub> Solid Solution Films on (100)cSrRuO <sub>3</sub> âˆ“(100)SrTiO <sub>3</sub> by Hydrothermal Method and Their Characterization. Japanese Journal of Applied Physics, 2011, 50, 09ND11.	1.5	10
68	Determination of diffusion coefficients by means of normal pulse polarography.. Analytical Sciences, 1990, 6, 239-243.	1.6	9
69	Ferroelectric Properties of Dysprosium-Substituted Lead Zirconate Titanate Thin Films Fabricated by Chemical Solution Deposition. Japanese Journal of Applied Physics, 2004, 43, 6558-6561.	1.5	9
70	Visualized Kinetic Aspects of a Wood Block in Sub- and Supercritical Water Oxidation. Industrial & Engineering Chemistry Research, 2006, 45, 5885-5890.	3.7	9
71	Site Occupancy Analysis on the Enhancement in Dy-Substituted Pb(Zr,Ti)O <sub>3</sub> Film. Japanese Journal of Applied Physics, 2006, 45, 7548-7551.	1.5	9
72	Pt Segregation at the NiSi/Si Interface and a Relationship with the Microstructure of NiSi. Materials Research Society Symposia Proceedings, 2008, 1070, 1.	0.1	9

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73	Preparation of (001)-Oriented CaBi <sub>4</sub> Ti <sub>4</sub> O <sub>15</sub> and SrBi <sub>4</sub> Ti <sub>4</sub> O <sub>15</sub> Films Using LaNiO <sub>3</sub> Nucleation Layer on Pt-passivated Si Wafer. Japanese Journal of Applied Physics, 2009, 48, 09KA10.	1.5	9
74	Preparation of preferentially (111)-oriented Mg <sub>2</sub> Si thin films on (001)Al <sub>2</sub> O <sub>3</sub> and (100)CaF <sub>2</sub> substrates and their thermoelectric properties. Japanese Journal of Applied Physics, 2017, 56, 05DC02.	1.5	9
75	High yield preparation of (100)c-oriented (K,Na)NbO <sub>3</sub> thick films by hydrothermal method using amorphous niobium source. Journal of the Ceramic Society of Japan, 2020, 128, 512-517.	1.1	9
76	Measurement Technique for the Evaluation of Residual Stress in Epitaxial Thin Film by Asymmetric X-Ray Diffraction.. Journal of the Ceramic Society of Japan, 1999, 107, 606-610.	1.3	8
77	Kinetic aspects of SCWO progress of solid organic substances. Chemical Engineering Science, 2007, 62, 5070-5073.	3.8	8
78	Contact resistance reduction of Pt-incorporated NiSi for continuous CMOS scaling &#x223C; Atomic level analysis of Pt/B/As distribution within silicide films &#x223C;, , 2008, , .		8
79	Unusual 90° domain structure in (2/3)Bi(Zn <sub>1/2</sub> Ti <sub>1/2</sub> )O <sub>3</sub> -(1/3)BiFeO <sub>3</sub> epitaxial films with giant 22% tetragonal distortion. Applied Physics Letters, 2013, 103, .	3.3	8
80	Fabrication and characterization of (110)-oriented (Ba <sub>0.5</sub> ,Sr <sub>0.5</sub> )TiO <sub>3</sub> thin films using PdO//Pd buffer layer. Japanese Journal of Applied Physics, 2015, 54, 10NA15.	1.5	8
81	Thermally stable dielectric responses in uniaxially (001)-oriented CaBi <sub>4</sub> Ti <sub>4</sub> O <sub>15</sub> nanofilms grown on a Ca <sub>2</sub> Nb <sub>3</sub> O <sub>10</sub> nanosheet seed layer. Scientific Reports, 2016, 6, 20713.	3.3	8
82	Growth of epitaxial tetragonal (Bi,K)TiO <sub>3</sub> films and their ferroelectric and piezoelectric properties. Japanese Journal of Applied Physics, 2016, 55, 10TA13.	1.5	8
83	Effect of Ta-substitution on the deposition of (K,Na)(Nb,Ta)O <sub>3</sub> films by hydrothermal method. Japanese Journal of Applied Physics, 2019, 58, SLLB12.	1.5	8
84	Good piezoelectricity of self-polarized thick epitaxial (K,Na)NbO <sub>3</sub> films grown below the Curie temperature (240°C) using a hydrothermal method. Applied Physics Letters, 2020, 117, .	3.3	8
85	Low-temperature deposition of Li substituted (K,Na)NbO <sub>3</sub> films by a hydrothermal method and their structural and ferroelectric properties. Journal of the Ceramic Society of Japan, 2019, 127, 388-393.	1.1	8
86	MD simulation of crystal growth from MgO melt. Journal of Molecular Liquids, 2002, 98-99, 191-200.	4.9	7
87	MOCVD growth and characterization of BiFeO <sub>3</sub> –Bi(Zn <sub>1/2</sub> Ti <sub>1/2</sub> )O <sub>3</sub> ferroelectric films. Materials Science and Engineering B: Solid-State Materials for Advanced Technology, 2010, 173, 14-17.	3.5	7
88	Effects of heat treatment on electrical and electromechanical properties of hydrothermally synthesized epitaxial (K <sub>0.51</sub> Na <sub>0.49</sub> )NbO <sub>3</sub> films. Japanese Journal of Applied Physics, 2014, 53, 05FE02.	1.5	7
89	Inhomogeneous distribution of manganese atoms in ferromagnetic ZnSnAs <sub>2</sub> :Mn thin films on InP revealed by three-dimensional atom probe investigation. Journal of Applied Physics, 2015, 117, .	2.5	7
90	Crystal structure and compositional analysis of epitaxial (K <sub>0.56</sub> Na <sub>0.44</sub> )NbO <sub>3</sub> films prepared by hydrothermal method. Journal of Materials Research, 2016, 31, 693-701.	2.6	7

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91	Deposition of orientation-controlled thick (K,Na)NbO <sub>3</sub> films on metal substrates by repeated hydrothermal deposition technique. Journal of the Ceramic Society of Japan, 2019, 127, 478-484.	1.1	7
92	Origin of Grain Size Effects on Voltage-Driven Ferroelastic Domain Evolution in Polycrystalline Tetragonal Lead Zirconate Titanate Thin Film. Advanced Functional Materials, 2020, 30, 1909100.	14.9	7
93	Role of alkan-1-ol solvents in the synthesis of yellow luminescent carbon quantum dots (CQDs): van der Waals force-caused aggregation and agglomeration. RSC Advances, 2020, 10, 14396-14402.	3.6	7
94	Rapid deposition of (K,Na)NbO <sub>3</sub> thick films using microwave-assisted hydrothermal technique. Japanese Journal of Applied Physics, 2020, 59, SPPB02.	1.5	7
95	Synthesis and Antioxidant Activity of Silver Nanoparticles Using the Odontonema strictum Leaf Extract. Molecules, 2022, 27, 3210.	3.8	7
96	Morphology change under pulsed laser irradiation of carbon particles suspended in water. Carbon, 2006, 44, 3356-3358.	10.3	6
97	Polar-axis-oriented crystal growth of tetragonal PZT films on stainless steel substrate using pseudo-perovskite nanosheet buffer layer. AIP Advances, 2015, 5, .	1.3	6
98	Preparation of Ca-Si Films on (001) Al <sub>2</sub> O <sub>3</sub> Substrates by an RF Magnetron Sputtering Method and Their Electrical Properties. Journal of Electronic Materials, 2016, 45, 3121-3126.	2.2	6
99	Crystal Orientation Control of Bismuth Layer-Structured Dielectric Films Using Interface Layers of Perovskite-Type Oxides. Japanese Journal of Applied Physics, 2011, 50, 09NA04.	1.5	6
100	MD simulation of crystal growth from CaCl <sub>2</sub> melt. Journal of Molecular Liquids, 2003, 103-104, 371-385.	4.9	5
101	Perovskite Single-Phase Growth of Epitaxial Pb(Zn <sub>1/3</sub> Nb <sub>2/3</sub> )O <sub>3</sub> Films by Alternative-Source-Gas-Introduced Metalorganic Chemical Vapor Deposition. Japanese Journal of Applied Physics, 2005, 44, L1452-L1455.	1.5	5
102	Fabrication of (100)-oriented Mn-doped bismuth ferrite films on silicon and stainless steel substrates using calcium niobate nanosheets. Journal of the Ceramic Society of Japan, 2015, 123, 322-328.	1.1	5
103	Orientation control of barium titanate films using metal oxide nanosheet layer. Japanese Journal of Applied Physics, 2016, 55, 10TA15.	1.5	5
104	Synthesis of TiO <sub>2</sub> hollow particles with highly dispersed CaCO <sub>3</sub> template particulates and their photoactivity toward a VOC pollutant. Journal of Sol-Gel Science and Technology, 2016, 78, 373-381.	2.4	5
105	Control of p- and n-type Conduction in Thermoelectric Non-doped Mg <sub>2</sub> Si Thin Films Prepared by Sputtering Method. MRS Advances, 2018, 3, 1355-1359.	0.9	5
106	Effect of the Residual Stress Induced by External Stress Application on Dielectric Properties of Epitaxial Lead Titanate Film.. Journal of the Ceramic Society of Japan, 2000, 108, 21-25.	1.3	4
107	Structural and Electrical Properties of Polycrystalline Bi <sub>4-x</sub> Nd <sub>x</sub> Ti <sub>3</sub> O <sub>12</sub> Ferroelectric Thin Films with in-Plane c-Axis Orientations. Japanese Journal of Applied Physics, 2005, 44, L292-L294.	1.5	4
108	Dispersion of barium titanate and strontium titanate nanocubes and their selective accumulations. Journal of the Ceramic Society of Japan, 2010, 118, 688-690.	1.1	4

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109	Structural and dielectric properties of BaTiO <sub>3</sub> –Bi(Mg <sub>1/2</sub> Ti <sub>1/2</sub> )O <sub>3</sub> thin films fabricated by chemical solution deposition. Japanese Journal of Applied Physics, 2014, 53, 09PA11.	1.5	4
110	Lead- and alkali-metal-free BaTiO <sub>3</sub> –Bi(Mg <sub>0.5</sub> Ti <sub>0.5</sub> )O <sub>3</sub> –BiFeO <sub>3</sub> solid-solution thin films with high dielectric constant prepared on Si substrates by solution-based method. Japanese Journal of Applied Physics, 2014, 53, 09PA12.	1.5	4
111	HCM12A Cr-rich oxide layer investigation using 3D atom probe. Journal of Nuclear Materials, 2014, 450, 237-243.	2.7	4
112	Simultaneous achievement of high dielectric constant and low temperature dependence of capacitance in (111)-oriented BaTiO <sub>3</sub> -Bi(Mg <sub>0.5</sub> Ti <sub>0.5</sub> )O <sub>3</sub> -BiFeO <sub>3</sub> solid solution thin films. AIP Advances, 2016, 6, .	1.3	4
113	Angular dependence of Raman spectrum for Pb(Zr,Ti)O <sub>3</sub> epitaxial films. Japanese Journal of Applied Physics, 2016, 55, 10TC07.	1.5	4
114	Facile preparation of N-doped TiO <sub>2</sub> at ambient temperature and pressure under UV light with 4-nitrophenol as the nitrogen source and its photocatalytic activities. Photochemical and Photobiological Sciences, 2016, 15, 1061-1070.	2.9	4
115	Epitaxial growth of Mg <sub>2</sub> Si films on (111) Si substrates covered with epitaxial SiC layers. Japanese Journal of Applied Physics, 2020, 59, SF1001.	1.5	4
116	Barkhausen noise analysis of thin film ferroelectrics. Applied Physics Letters, 2020, 117, 012902.	3.3	4
117	Synthesis and Electrical Properties of Sr- and Nb-Cosubstituted Bi <sub>4-x</sub> Sr <sub>x</sub> Ti <sub>3-x</sub> Nb <sub>x</sub> O <sub>12</sub> Polycrystalline Thin Films. Japanese Journal of Applied Physics, 2003, 42, L949-L952.	1.5	3
118	Synthesis and Properties of Nd-Substituted Bismuth Titanate Polycrystalline Thin Films with Polar-Axis Orientation. Key Engineering Materials, 2004, 269, 53-56.	0.4	3
119	A new SrBi <sub>4</sub> Ti <sub>4</sub> O <sub>15</sub> /CaBi <sub>4</sub> Ti <sub>4</sub> O <sub>15</sub> thin-film capacitor for excellent electric stability. IEEE Transactions on Ultrasonics, Ferroelectrics, and Frequency Control, 2012, 59, 1888-1893.	3.0	3
120	Orientation and film thickness dependencies of (100)- and (111)-oriented epitaxial Pb(Mg <sub>1/3</sub> Nb <sub>2/3</sub> )O <sub>3</sub> films grown by metal organic chemical vapor deposition. Journal of Materiomics, 2015, 1, 188-195.	5.7	3
121	Fabrication and characterization of {110}-oriented Pb(Zr,Ti)O <sub>3</sub> thin films on Pt/SiO <sub>2</sub> /Si substrates using PdO//Pd buffer layer. Japanese Journal of Applied Physics, 2017, 56, 10PF09.	1.5	3
122	Preparation of CaMgSi and Ca <sub>7</sub> Mg <sub>7.25</sub> Si <sub>14</sub> single phase films and their thermoelectric properties. MRS Advances, 2019, 4, 1503-1508.	0.9	3
123	Strong Dependence on Thickness of Room-Temperature Dielectric Constant of (100)-Oriented Pb(Mg <sub>1/3</sub> Nb <sub>2/3</sub> )O <sub>3</sub> Epitaxial Films Grown by Metal Organic Chemical Vapor Deposition. Japanese Journal of Applied Physics, 2006, 45, L1074-L1076.	1.5	2
124	Synthesis of Oxide Thin Films on Silicon Substrate Using Supercritical Carbon Dioxide Fluid. Key Engineering Materials, 2006, 320, 91-94.	0.4	2
125	Synthesis and Properties of Nd-Substituted Bismuth Titanate Polycrystalline Thin Films with a-/b-Axes Orientation. Key Engineering Materials, 2006, 301, 57-60.	0.4	2
126	Single-phase Pb(Zn <sub>1/3</sub> Nb <sub>2/3</sub> )O <sub>3</sub> thin films grown by metalorganic chemical vapor deposition: Effects of growth sequence and substrates. Journal of Crystal Growth, 2007, 298, 495-499.	1.5	2



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127	Dielectric Properties of Highly (001)-Plane Oriented SrBi <sub>4</sub> Ti <sub>4</sub> O <sub>15</sub> Thin Films. Key Engineering Materials, 2010, 445, 131-134.	0.4	2
128	Dielectric property of (001) one-axis oriented CaBi <sub>4</sub> Ti <sub>4</sub> O <sub>15</sub> -based thin films and their temperature dependence. Journal of the Ceramic Society of Japan, 2014, 122, 477-482.	1.1	2
129	Chemical Fluid Deposition of Hf-Zr-O-based Thin Films using Supercritical Carbon Dioxide Fluid. Materials Research Society Symposia Proceedings, 2015, 1729, 99-104.	0.1	2
130	Chemical deposition of silica-based thin films under supercritical carbon dioxide atmosphere using tetraethylorthosilicate precursor with oxidizing agents. Journal of the Ceramic Society of Japan, 2016, 124, 18-22.	1.1	2
131	Dielectric properties of BaTiO <sub>3</sub> &ndash; Bi(Mg <sub>1/2</sub> Ti <sub>1/2</sub> O <sub>3</sub> ) <sub>z</sub> films with preferential crystal orientation. Journal of the Ceramic Society of Japan, 2016, 124, 648-652.		
132	Time response demonstration of in situ lattice deformation under an applied electric field by synchrotron-based time-resolved X-ray diffraction in polar-axis-oriented epitaxial Pb(Zr,Ti)O <sub>3</sub> film. Japanese Journal of Applied Physics, 2018, 57, 0902B8.	1.5	2
133	Polarization switching behavior of one-axis-oriented lead zirconate titanate films fabricated on metal oxide nanosheet layer. Japanese Journal of Applied Physics, 2017, 56, 10PF10.	1.5	2
134	Enhancement of Remanent Polarization of BIT-based Thin Films by Ti-site Substitution using Ions with Higher Charge Valences. Materials Research Society Symposia Proceedings, 2002, 748, 1.	0.1	1
135	Improvement of Ferroelectric Properties of Lead Zirconate Titanate Thin Films by Ion-substitution using Rare-earth Cations. Materials Research Society Symposia Proceedings, 2004, 830, 165.	0.1	1
136	Characterization of zinc-modified lithium tantalate thin films fabricated by chemical solution deposition method. Journal of Sol-Gel Science and Technology, 2007, 42, 265-269.	2.4	1
137	Low-Temperature Processing of Sol-Gel Derived Metal Oxide Thin Films using Supercritical Carbon Dioxide Fluid. Materials Research Society Symposia Proceedings, 2008, 1113, 1.	0.1	1
138	Pulsed-laser Irradiation to Suspended Carbon Particles in Aqueous Silver Nitrate Solution. Chemistry Letters, 2008, 37, 818-819.	1.3	1
139	Dispersion of Barium Titanate and Strontium Titanate Nanocubes and their Selective Accumulations. Key Engineering Materials, 0, 445, 183-186.	0.4	1
140	Dielectric Property of Silicate-Doped CaBi <sub>4</sub> Ti <sub>4</sub> O <sub>15</sub> Thin Films. Japanese Journal of Applied Physics, 2012, 51, 09LA16.	1.5	1
141	Identification of the Occupation Site of Dy- or Y-Substituted PZT Films and the Correlation Between Occupation Site and Ferroelectric Property. Integrated Ferroelectrics, 2013, 141, 1-8.	0.7	1
142	One-Axis-Oriented Crystal Growth of Lead Zirconate Titanate Thin Films on Metal Substrates Using Perovskite-Type Oxide Nanosheet Layer. Key Engineering Materials, 2013, 582, 15-18.	0.4	1
143	Investigation of mixing effects of silicon isotopes under shave-off condition using atom probe tomography. Surface and Interface Analysis, 2014, 46, 1200-1203.	1.8	1
144	Reconstruction in Atom Probe Tomography Considering the Cone Angle of Needle-Like Shaped Samples and Evaluation of Reliability. E-Journal of Surface Science and Nanotechnology, 2015, 13, 235-238.	0.4	1

#	ARTICLE	IF	CITATIONS
145	Atom probe tomography study on $\text{Ge}_{1-x}\text{Sn}_x\text{Cy}$ hetero-epitaxial film on Ge substrates. <i>Thin Solid Films</i> , 2015, 592, 54-58.	1.8	1
146	Solid-solution thin films of ternary $\text{BaTiO}_3\text{-Bi}(\text{Mg}_{1/2}\text{Ti}_{1/2})\text{O}_3\text{-BiFeO}_3$ system epitaxially grown on $\text{SrRuO}_3/\text{SrTiO}_3$ substrates via chemical solution process. <i>Japanese Journal of Applied Physics</i> , 2018, 57, 0902B5.	1.5	1
147	Composition Dependence of Crystal Structures and Electrical Properties of Ca-Mg-Si Films Prepared by Sputtering. <i>Journal of Electronic Materials</i> , 2020, 49, 7509-7517.	2.2	1
148	Influence of Internal Strains of (110)-One-Axis-Oriented $(\text{Ba}_{0.5}\text{Sr}_{0.5})\text{TiO}_3$ (BST) Thin Films on Their Dielectric Behaviors. <i>Science of Advanced Materials</i> , 2017, 9, 1806-1809.	0.7	1
149	Lower-temperature processing of potassium niobate films by microwave-assisted hydrothermal deposition technique. <i>Journal of the Ceramic Society of Japan</i> , 2022, 130, 123-130.	1.1	1
150	One-axis-oriented growth of PZT thin films on transparent glass substrates using metal oxide nanosheets. <i>Japanese Journal of Applied Physics</i> , 2022, 61, SN1006.	1.5	1
151	Ti-site Substitution Using the Higher-valent Cation for Enhancing the Ferroelectric Properties of $\text{Nd}^{3+}$ -substituted Bismuth Titanate Thin Films. <i>Materials Research Society Symposia Proceedings</i> , 2003, 784, 1181.	0.1	0
152	Enhanced Spontaneous Polarization of Dysprosium-substituted Lead Zirconate Titanate Thin Films by a Chemical Solution Deposition Method. <i>Materials Research Society Symposia Proceedings</i> , 2004, 830, 293.	0.1	0
153	Ion Modification for Improvement of Electrical Properties of Perovskite-based Ferroelectric Thin Films Fabricated by Chemical Solution Deposition Method. <i>Materials Research Society Symposia Proceedings</i> , 2005, 902, 1.	0.1	0
154	Electrical Properties of Perovskite-Based Ferroelectric Thin Films Modified Using Rare-Earth Elements. <i>Key Engineering Materials</i> , 2006, 320, 49-52.	0.4	0
155	Bi-based ferroelectric thin films with enhanced polarization by rare-earth modification. <i>Applications of Ferroelectrics</i> , IEEE International Symposium on, 2007, , .	0.0	0
156	Preparation and characterization of Bi-perovskite oxide films for piezo applications. <i>Applications of Ferroelectrics</i> , IEEE International Symposium on, 2007, , .	0.0	0
157	Effect of the Annealing Temperature on Dielectric Properties of $\text{Bi}_{1.5}\text{Zn}_{1.0}\text{Nb}_{1.5}\text{O}_{7.4}$ Films Prepared by MOCVD. <i>Key Engineering Materials</i> , 0, 388, 175-178.		0
158	One-axis Oriented $\text{CaBi}_4\text{Ti}_4\text{O}_{15}$ and $\text{SrBi}_4\text{Ti}_4\text{O}_{15}$ Films Prepared on Silicon Wafer by Chemical Solution Deposition Technique. <i>Materials Research Society Symposia Proceedings</i> , 2009, 1199, 54.	0.1	0
159	Pulsed-laser Irradiation of Carbonaceous Materials in $\text{AgNO}_3$ Solution and Its Application to Preparing Silver-activated Carbon Electrodes. <i>Chemistry Letters</i> , 2010, 39, 561-563.	1.3	0
160	Growth of polar axis oriented tetragonal $\text{Pb}(\text{Zr,Ti})\text{O}_3$ films on $\text{CaF}_2$ substrates with transparent $(\text{La}_{0.07}\text{Sr}_{0.93})\text{SnO}_3$ . <i>Journal of Crystal Growth</i> , 2010, 312, 3127-3130.	1.5	0
161	Investigation of $\text{SrBi}_4\text{Ti}_4\text{O}_{15}/\text{CaBi}_4\text{Ti}_4\text{O}_{15}$ thin film capacitor for excellent electric stability. , 2011, , .		0
162	A New $\text{SrBi}_4\text{Ti}_4\text{O}_{15}/\text{CaBi}_4\text{Ti}_4\text{O}_{15}$ thin film capacitor for excellent electric stability. , 2011, , .		

#	ARTICLE	IF	CITATIONS
163	Dielectric Properties of Bismuth Layer-Structured Oxide Thin Films with Preferential Crystal Orientation at High-Temperature. Key Engineering Materials, 0, 485, 191-194.	0.4	0
164	Development of novel Pb, Li, Na and K-free piezoelectric materials for Si-based MEMS application. , 2012, , .		0
165	Preparation of (La,Sr)MnO <sub>3</sub> Thin Film by Chemical Solution Deposition. Key Engineering Materials, 2013, 566, 187-190.	0.4	0
166	Fabrication of BiFeO <sub>3</sub> -Bi(Zn <sub>1/2</sub> Ti <sub>1/2</sub> )O <sub>3</sub> Solid Solution Thin Films Using Perovskite-Type Oxide Interface Layer. Key Engineering Materials, 0, 566, 163-166.	0.4	0
167	Leakage current characteristics of new SrBi <sub>4</sub> Ti <sub>4</sub> O <sub>15</sub> /CaBi <sub>4</sub> Ti <sub>4</sub> O <sub>15</sub> thin-film capacitor with excellent electric stability. , 2013, , .		
168	Probing Oxygen Vacancies in BaTiO <sub>3</sub> Powders and Single Crystals by Micro-Raman Scattering. Advanced Structured Materials, 2017, , 65-75.	0.5	0
169	Kinetics of interfacial microstructural variation across insulator-thermoelectric semiconductor interface and its effects on thermoelectric properties of magnesium silicide thin films. Materialia, 2019, 7, 100375.	2.7	0
170	Dielectric Property of Silicate-Doped CaBi <sub>4</sub> Ti <sub>4</sub> O <sub>15</sub> Thin Films. Japanese Journal of Applied Physics, 2012, 51, 09LA16.	1.5	0
171	Hydrothermal Deposition of KNbO <sub>3</sub> Films on Metal Substrates having Three-Dimensional Structure. Funtai Oyobi Fumatsu Yakin/Journal of the Japan Society of Powder and Powder Metallurgy, 2018, 65, 673-677.	0.2	0